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| Application No. <u>09921074</u> | Prepared by <u>ewc</u> | Tracking Number <u>05913639</u> | |
| Examiner-GAU <u>Easthorn</u> | Date <u>2-22-04</u> | Week Date <u>3-01-04</u> | |
| <u>2832</u> | No. of queries <u>-1-</u> | <u>IFW</u> | |

| JACKET | | | |
|----------------------|------------------------|--------------------|----------------|
| a. Serial No. | f. Foreign Priority | k. Print Claim(s) | p. PTO-1449 |
| b. Applicant(s) | g. Disclaimer | l. Print Fig. | q. PTOL-85b |
| c. Continuing Data | h. Microfiche Appendix | m. Searched Column | r. Abstract |
| d. PCT | i. Title | n. PTO-270/328 | s. Sheets/Figs |
| e. Domestic Priority | j. Claims Allowed | o. PTO-892 | t. Other |

| SPECIFICATION | MESSAGE |
|------------------------|---|
| a. Page Missing | <p>Please supply dates for foreign patent documents. Moly is necessary for publication. If unavailable, please line through citations.</p> <p>Thank you ewc</p> |
| b. Text Continuity | |
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| e. Illegible Text | |
| f. Duplicate Text | |
| g. Brief Description | |
| h. Sequence Listing | |
| i. Appendix | |
| j. Amendments | |
| k. Other | |
| CLAIMS | |
| a. Claim(s) Missing | |
| b. Improper Dependency | |
| c. Duplicate Numbers | |
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| e. Index Disagrees | initials |
| f. Punctuation | RESPONSE <u>OK - data supplied.</u> |
| g. Amendments | <u>no mailing necessary</u> |
| h. Bracketing | |
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| k. Other | 5/1/14 initials |

Form PTO-1449
Attorney Docket: GD7240US.CIP

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PAPERS
2-5

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

INFORMATION DISCLOSURE CITATION

In re application of: Jiangtao Wang et al.

Serial No: 09/921,074

Group No.: 3729

Filed: August 2, 2001

Examiner: Not yet known

For: RESISTOR COMPONENT WITH MULTIPLE LAYERS
OF RESISTIVE MATERIAL

Assistant Commissioner for Patents
Washington, DC 20231

U.S. Patent Documents

| Examiner Initials | Document Number | Date | Name | Class |
|----------------------|--------------------|------------|-----------|--------|
| <u>ce</u> | 2,662,957 | 12/15/1953 | P. Eisler | 201/73 |

Foreign Patent Documents

| Examiner Initials | Document Number | Country | Class | Translation (Yes/No) |
|----------------------|--------------------|---------|----------------|-------------------------|
| <u>ce</u> | 690,691 | England | 36, 37 and 140 | yes (4/1953) |
| <u>u</u> | EP 0 007 598 | Europe | H 01 C 7/00 | yes (2/1980) |

Examiner:

Date Considered:

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**Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.